



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#6
12
5/20/02

Re Patent Application of: Young-Hee MUN

Serial No.: 09/742,127

Group Art Unit: 1765

Filed: December 22, 2000

Examiner: Song, Matthew J.

For: METHOD OF TREATING A SEMICONDUCTOR WAFER THERMALLY AND
SEMICONDUCTOR WAFER FABRICATED BY THE SAME

* * * * *

RESPONSE TO RESTRICTION REQUIREMENT

Honorable Commissioner for Patent
Washington, D.C. 20231

May 16, 2002

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Sir:

In response to the Request for Restriction mailed April 30, 2002 (Paper No. 5), Applicant elects Group I, claims 1-8 and 17-19, drawn to a process, classified in class 438, subclass 795, without traverse.

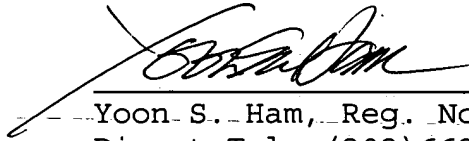
An early Office Action on the merits is respectfully requested.

If a Petition for Extension is necessary and the petition and/or check is not enclosed, this will act as a petition to extend the time for response and authorization to charge the necessary fees under 37 CFR 1.17(a)-(d) to Deposit Account 06-1358.

May 16, 2002

Serial No.: 09/742,127
Atty. Docket No.: P66182US0

Respectfully submitted,



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Enclosures